

AMENDMENTS TO THE ABSTRACT:

Please replace the Abstract originally appearing on page 28 of the application with the following rewritten paragraph:

ABSTRACT OF THE DISCLOSURE

A selective deposition system and method for initiating deposition of an unconsolidated material at a defined starting surface are disclosed. The system includes a sensor system for measuring an upper surface of a workpiece and a surface level of the unconsolidated material as deposited on the upper surface of the workpiece. The deposition process and measurement of the upper surface of the material on the workpiece are continuously performed as the material is applied in a layer by layer deposition process resulting in a substantially uniform material of a predetermined ~~thickness on~~ thickness beginning at the upper surface of the workpiece.